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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT : Keun Deok Park

SERIAL NO. : 10/607,156 EXAMINER : Daniel S. Metzmaier

FILED : June 26, 2003 ART UNIT : 1712

FOR : COLLOIDAL SILICA COMPOSITION AND PRODUCTION METHOD  
THEREOF

RESPONSE TO REQUIREMENT FOR RESTRICTION  
UNDER 35 U.S.C. §121  
And  
PRELIMINARY AMENDMENT

MAIL STOP AMENDMENT  
COMMISSIONER FOR PATENTS  
P.O. BOX 1450  
ALEXANDRIA, VA. 22313

Dear Sir:

Responsive to the Office Action dated June 23, 2005, issued in connection with the above-identified Application, which is now due for response on July 23, 2005, please consider the following remarks.